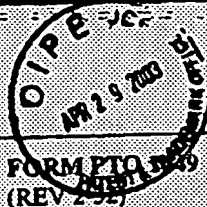


QUERY CONTROL FORM			RTIS USE ONLY		
Application No.	09/728911	Prepared by	A. Connelly	Tracking Number	05996923
Examiner-GAU	Gambel 1644	Date	9/23/04	Week Date	8/16/04
		No. of queries	(1)		FFW Reuse T-4

JACKET			
a. Serial No.	f. Foreign Priority	k. Print Claim(s)	p. PTO-1449
b. Applicant(s)	g. Disclaimer	l. Print Fig.	q. PTOL-85b
c. Continuing Data	h. Microfiche Appendix	m. Searched Column	r. Abstract
d. PCT	i. Title	n. PTO-270/328	s. Sheets/Figs
e. Domestic Priority	j. Claims Allowed	o. PTO-892	t. Other

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Sheet 1 of 1

FORM PTO-503
(REV. 2-95)U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

File No. 99-93

Serial No.
09728,911

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

Applicant(s):
Scott R. Presnell, Wenfeng Xu, Wayne
Kindsvogel, Zhi ChenFiling Date:
December 1, 2000

Group: 1645

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
						RECEIVED
						MAY 01 2003
						TECH CENTER 1600/2900

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A1	WO98/37193	27.08.2001	WIPO		
	A2	WO01/736467	25.05.2001	WIPO		
	A3	WO02/066647	29.08.2002	WIPO		
	A4	WO02/024912	28.03.2002	WIPO		

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	A5	Dumoutier, L et al., J. Immunol. 167:3545-3549, 2001
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	A8	Xu, W et al., Proc. Nat. Acad. Sci. 98:9511-9516, 2001
	A9	Gruenberg, BH et al., Genes and Immunity 2:329-334, 2001
	A10	Xu, X. et al., EMBL Database, Chinese National Human Genome Center at Shanghai, 5 Oct. 2000: AV714177
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Examiner

Date considered

EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.